

Electronic Acknowledgement Receipt

EFS ID:	1100833
Application Number:	10770711
Confirmation Number:	2278
Title of Invention:	Predicting defect future effects in integrated circuit technology development to facilitate semiconductor wafer lot disposition
First Named Inventor:	Paul J. Steffan
Customer Number:	22898
Filer:	Mikio Ishimaru/Vickie Ishimaru
Filer Authorized By:	Mikio Ishimaru
Attorney Docket Number:	H0897
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Application Type:	Utility
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File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part	Pages
1		H0897_Amendment.pdf	620760	yes	12

	Multipart Description		
	Doc Desc	Start	End
	Amendment - After Non-Final Rejection	1	1
	Claims	2	5
	Applicant Arguments/Remarks Made in an Amendment	6	12

Warnings:

Information:

Total Files Size (in bytes):	620760
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New Applications Under 35 U.S.C. 111

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.